## (19) World Intellectual Property **Organization**

International Bureau





(43) International Publication Date 15 September 2005 (15.09.2005)

PCT

## (10) International Publication Number WO 2005/085354 A1

(51) International Patent Classification7: C08K 5/00

C08L 71/02,

(21) International Application Number:

PCT/JP2005/004404

(22) International Filing Date: 8 March 2005 (08.03.2005)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:

2004-067900 10 March 2004 (10.03.2004)

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- (81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.
- (84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

## Published:

with international search report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: POLYETHER COMPOSITION

(57) Abstract: An object of the present invention is to provide a polyether composition that can suppress reduction in a molecular weight of polyether having a low glass transition temperature and melting point. As a means of achieving this object, a polyether composition of the present invention contains polyether having a glass transition temperature of -50 <sub>o</sub>C or lower and a melting point of 55 °C or lower and, at the same time, contains at least one kind selected from the group consisting of compounds represented by the specified three general formulas.